

L Number	Hits	Search Text	DB	Time stamp
1	251	438/42	USPAT	2004/07/11 14:09
2	229	438/43	USPAT	2004/07/11 14:09
3	725	438/48	USPAT	2004/07/11 14:09
4	1069	438/455	USPAT	2004/07/11 14:09
5	316	438/456	USPAT	2004/07/11 14:09
6	131	438/457	USPAT	2004/07/11 14:09
7	1029	438/680	USPAT	2004/07/11 14:10
8	509	438/681	USPAT	2004/07/11 14:10
9	1307	438/700	USPAT	2004/07/11 14:10
10	530	438/704	USPAT	2004/07/11 14:10
11	793	438/712	USPAT	2004/07/11 14:10
12	705	438/734	USPAT	2004/07/11 14:10
13	957	438/738	USPAT	2004/07/11 14:10
14	3067	438/692	USPAT	2004/07/11 14:10
-	0	microstructures and (arrangement adj2 microstructures) and cavities and (regular adj arrangement) and trenches	USPAT	2004/07/11 12:50
-	0	(closed adj cavities) and (arrangement adj2 microstructures) and cavities and pattern and trenches	USPAT	2004/07/11 12:52
-	2	microstructures and (arrangement adj2 microstructures) and cavities and pattern and trenches	USPAT	2004/07/11 12:52
-	12	microstructures and (arrangement adj2 microstructures) and cavities	USPAT	2004/07/11 12:54
-	12	(microstructures and (arrangement adj2 microstructures) and cavities) and (closed or off or cavities or cavity or opening or microstructure or pattern or patterning or regular or portion or partitions or depression or material cmp or trench or trneches or angle or "90" or degrees or etch or etching or oxygen or teos or oxide or silicon or nitride or metal or alloy or copper or grid or web)	USPAT	2004/07/11 13:15
-	1	("6201243").PN.	USPAT	2004/07/11 13:15
-	1	("6612917").PN.	USPAT	2004/07/11 13:15
-	1	("6717060").PN.	USPAT	2004/07/11 13:15
-	1	((("6201243").PN.) and (closed or off or cavities or cavity or opening or microstructure or pattern or patterning or regular or portion or partitions or depression or material cmp or trench or trneches or angle or "90" or degrees or etch or etching or oxygen or teos or oxide or silicon or nitride or metal or alloy or copper or grid or web)	USPAT	2004/07/11 13:16
-	1	((("6612917").PN.) and (closed or off or cavities or cavity or opening or microstructure or pattern or patterning or regular or portion or partitions or depression or material cmp or trench or trneches or angle or "90" or degrees or etch or etching or oxygen or teos or oxide or silicon or nitride or metal or alloy or copper or grid or web)	USPAT	2004/07/11 14:09
-	1	((("6717060").PN.) and (closed or off or cavities or cavity or opening or microstructure or pattern or patterning or regular or portion or partitions or depression or material cmp or trench or trneches or angle or "90" or degrees or etch or etching or oxygen or teos or oxide or silicon or nitride or metal or alloy or copper or grid or web)	USPAT	2004/07/11 13:17

7/11/04